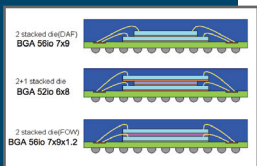
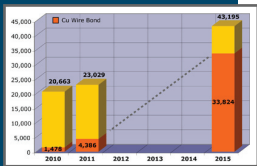
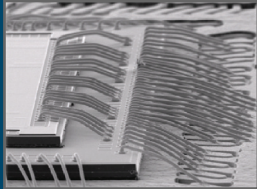


Advanced Packaging Update: Market and Technology Trends

Vol. 1-011



This volume of the Advanced Packaging Update features special coverage of the transition to copper wire bonding. Information from suppliers of wire, users, and assembly houses provide a clear trend. Wire shipment data was collected from the leading suppliers to determine both the bare copper and palladium-coated copper markets. The adoption of copper wire bonding in PBGAs, FBGAs, QFNs, and stacked die CSPs is documented. An update on automotive electronics is included. New developments in test for TSV wafers are featured. A section on new package developments focuses on TI's 3D stacked QFN package for power devices such as MOSFETs. The report also examines economic trends and the impact on the semiconductor industry.

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